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METHOD FOR PRODUCING MICROCHANNELS HAVING CIRCULAR
CROSS-SECTIONS IN GLASS

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[0001] The United States Government has rights in this invention pursuant to Contract No. W-7405-ENG-48 between the United States Department of Energy and the University of California for the operation of Lawrence Livermore National Laboratory.

BACKGROUND OF THE INVENTION

5 [0002] The present invention relates to the formation of microchannels, particularly to the formation of microchannels having a circular cross-section, and more particularly to a method for producing circular cross-section microchannels in glass.

10 [0003] Microfabrication has become an enabling technology for development of the generation of analytical instrumentation for performing medical diagnoses, sequencing the human genome, detecting air borne pathogens, and increasing throughput for combinatorial chemistry and drug discovery. These miniature devices take advantage of scaling laws and unique physical phenomena which occur at the micro-scale to perform new types of assays. The
15 large surface area to volume ratio and small size of microfabricated fluidic devices results in laminar flows, increased surface contact between sample fluids and electrodes, fast and uniform heat transfer, and reduced reagent use. Surface tension and viscous forces dominate while inertial effects are negligible.

[0004] Microfluidic devices with microelectrodes have the potential to enable studies of phenomena at size scales where behavior may be dominated by different mechanisms than at macroscales. Through work developing microfluidic devices for dielectrophoretic separation and sensing of cells and particles, we have fabricated devices from which general or more specialized research device may be derived. Fluid channels from $80\mu\text{m}$ wide \times $20\mu\text{m}$ deep to 1 mm wide \times $200\mu\text{m}$ deep have been fabricated in glass, with lithographically patterned electrodes from 10 to $80\mu\text{m}$ wide on one or both sides of the channels and over topographies tens of microns in height. The devices are designed to easily interface to electronic and fluidic interconnect packages that permit reuse of devices, rather than one-time use, crude glue-based methods. Such devices may be useful for many applications of interest to the electrochemical and biological community.

[0005] For microfluidics applications in which liquids or gasses pass within microchannels patterned into glass, silicon, or plastic substrates, channel cross-sections having sharp corners cause several problems: (1) fluid carryover trapped in corners can result in cross-contamination; (2) particles such as DNA and beads are easily trapped in corners; (3) corners can be a source of bubble nucleation and/or bubble entrapment; (4) separation efficiencies for applications such as gas chromatography are greatly reduced due to non-uniform diffusion rates out of corner areas. Current microfabrication techniques produce microchannels with rectangular or trapezoidal cross-sections when a planar substrate is bonded onto another substrate which has microchannels etched into it. It is possible to etch mirror-image semi-circular channels into opposing substrates, then bond the two together, but this involves a difficult and critical

alignment step. Microchannels with circular cross-sections are highly desirable, but until now have been extremely difficult, if not impossible, to achieve.

[0006] Recent efforts have been directed to forming smooth surface microchannels to prevent channel cross-sections having sharp corners to prevent trapping of particles in those sharp corners. These efforts are directed to forming microchannels with circular cross-sections. One approach involves etching a channel into a glass substrate, forming a layer of silicon on the channel surface, forming a layer of wax on the silicon layer, bonding a second plate over the wax, annealing whereby a circular channel is formed, and thereafter removing the wax.

[0007] The present invention provides another approach which basically involves etching a channel into a glass substrate, fusion bonding (or glass-glass anodic bonding) a glass substrate over the formed channel, and annealing the glass which transforms the channel cross-section to a circle. The method of the present invention can be utilized with a glass substrate containing etched channel and to which a silicon wafer is anodically bonded, and thereafter annealed. Other materials, such as polymers may be utilized in the present method.

SUMMARY OF THE INVENTION

[0008] It is an object of the present invention to produce microchannels having circular cross sections.

[0009] A further object of the invention is to provide a method for producing microchannels in glass having circular cross-sections.

[0010] Another object of the invention is to provide a method for micromachining capillaries having circular cross-sections in glass substrates.

[0011] Another object of the invention is to provide a method for creating glass microchannels with circular cross-sections by etching a channel into a glass substrate, fusion or anodically bonding a second glass substrate to the first substrate creating a sealed microchannel, and annealing the glass, transforming the channel cross-section to a circle.

[0012] Another object of the invention is to produce circular cross-section microchannel in devices which include glass, silicon, or polymer components.

[0013] Other objects and advantages of the invention will become apparent from the following description and accompanying drawings. The present invention involves a method for producing microchannels having circular cross-sections, particularly in glass substrates. The method is basically a three (3) step operation composed of etching, bonding, and annealing. Preferably the microchannels are etched into a glass substrate, a glass plate is fusion or anodically bonded to the substrate, and the bonded substrate and plate are then annealed, with circular microchannels being produced thereby. A silicon wafer can be anodically bonded to an etched glass substrate and then annealed to produce microchannels having circular cross-section. Other materials, such as polymers, may be utilized in the process of this invention

BRIEF DESCRIPTION OF THE DRAWINGS

[0014] Figure 1-3 illustrate the process of the present invention with Figure 1 showing an etched substrate, Figure 2 showing a plate fusion bonded to the

substrate, and Figure 3 showing a circular microchannel formed by annealing the bonded structure of Figure 2.

DETAILED DESCRIPTION OF THE INVENTION

5 [0015] The present invention relates to a method for micromachining capillaries having circular cross-sections, particularly in glass substrates. The invention overcomes the above-discussed problems associated with microchannels patterned into glass, silicon, or plastic substrates wherein the channel cross sections have sharp corners. Microchannels with circular cross-

10 sections are highly desirable, but previously have been extremely difficult, if not impossible, to achieve. The method of this invention is simple, cost effective, and produces satisfactory results. The method can be utilized with components composed of glass, silicon, or plastic, and is particularly effective using an etched glass substrate fusion bonded to a glass plate, and then annealed to a sufficiently

15 high temperature of 600° to 800°C, such as 750C to allow surface tension forces and diffusional effects to lower the over all energy of the microchannels by transferring the cross-section to a circular shape. If plastic (polymer) components are used the annealing temperature would be lowered to 200°C and above.

20 [0016] It is also possible, utilizing this invention, to form microchannels with circular cross-sections by etching channels into a glass substrate, then anodically bonding the etched glass substrate to a silicon wafer, followed by annealing, the annealing temperature involving silicon would be in the range of 600° to 800°C. The invention maybe utilized with substrates other than glass, such as silicon and polymers, in which microchannels are formed and top plates are bonded

25 thereto, after which annealing is carried out to produce rounded surfaces,

thereby eliminating any sharp corners formed when the top plate is bonded to the substrate containing the microchannels.

[0016] Figures 1-3 show the three fabrication steps involved in creating glass microchannels with circular cross-sections, the three steps being described as follows:

[0017] In step 1, a glass substrate 10, see Figure 1, is isotropically etched to form microchannels 11, only one shown. The microchannels can be etched to have various widths, depths, lengths, and configuration including straight, spiral, curved, etc. For example, spiral microchannels may be formed to make a gas or liquid chromatography column.

[0018] In step 2, a second glass cover substrate or top plate 12 is fusion (or anodic) bonded, see Figure 2, to the first substrate 10, sealing the microchannel 11. Note the undesirable sharp corners 13 of Figure 2. The process may also work if a silicon wafer is anodically bonded to the etched glass substrate 10 and may have certain advantages because anodic bonding is relatively inexpensive and a straight forward process compared to fusion bonding, and, for gas chromatography, the high thermal conductivity of silicon is advantageous. As seen in Figure 2, the fusion bonding of substrate 10 and plate 12 results in a unified device 14.

[0019] The bonding of step 2 of the process may be carried out as follows:

A matched pair of substrates must be precisely aligned, such as using lithographically patterned metal alignment markers, and bonded together.

Anodic bond of glass to glass is carried out at a temperature of 550°C ramping the oven over a 2.5 hour period. High voltage is applied and allowed to ramp to 1000V. The part is annealed for one hour at 550°C and cooled overnight or about 3 hour ramp down. Fusion bonding of the substrates, wherein the mated

thickness of 1mm, the annealing temperature would be 600° to 800°C, depending on the composition of the glass in substrate 10 and plate 12, and the annealing time to produce circular microchannels would be 5 to 20 hrs. It should be noted that if only rounded corners instead of the sharp corners 13 in Figure 2 and an oblong microchannel configuration were desired, the annealing time would be less.

[0021] Because the process of the invention is done in glass, a commonly used material for micromachining and a material where there is current micromachining expertise, other silicon and glass components such as injectors and sensors can be integrated along with the microchannels.

[0022] The invention has numerous applications in microfluidic systems, such as microfabricated instrument for chemical and biological analysis in gas and liquid state, in particular for chemical and biological warfare agent detection, DNA and protein analysis. Other uses may include columns for hand held gas chromatography, medical diagnostic microsystems incorporating microfluidic chips for genetic analysis and other assays, as well as in instruments for drug discovery and DNA sequencing.

[0023] It has thus been shown that the present invention provides a method for producing microchannels in glass having circular cross-sections, and that the method can be used for other materials, such as silicon and polymers.

[0024] While a specific example of the method of the invention, along with parameters for carrying of the invention, have been described and/or illustrated to exemplify and teach the principles of the invention, such are not intended to be limiting. Modifications and changes may become apparent to those skilled in the art, and it is intended that the invention be limited only by the scope of the appended claims.